	PROCESSES AND PRODUCTS	157.64	Nitrogen, sulfur, phosphorous or silicon containing product
Class 20	05 is an integral part of this		produced
Class (C	Class 204), as shown by the posi-	157.65	Carbocyclic ring containing
tion of	this box, and follows the schedule		product produced
hierarch	ny of this Class, retaining all	157.67	Vitamin product produced
pertiner	nt definitions and Class lines of	157.68	Carbohydrate or protein
this cla	ass.		product produced
		157.69	Heterocyclic product produced
		157.7	Hetero sulfur containing
		157.71	Hetero nitrogen containing
155	.Electrical, or wave energy in	157.72	Hetero nitrogen ring
	magnetic field		contains at least two hetero
156	With discharge		atoms
157.15	.Processes of treating materials	157.73	Phosphorous product produced
	by wave energy	157.74	Silicon product produced
157.2	Isotope separation or	157.75	Heavy metal product produced
	enrichment	157.76	Sulfur product produced
157.21	Inorganic product produced	157.77	Nitrogen containing
157.22	Using laser	157.78	Oxygen containing
157.3	Removing a component from	157.79	Halogen containing
	normally gaseous mixture	157.8	Halogen containing
157.4	Process of preparing desired	157.81	Nitrogen product produced
	inorganic material	157.82	Oxygen containing
157.41	Using laser	157.83	Nitroso or oxime containing
157.42	Using sonic or ultrasonic	157.84	Halogen containing
	energy	157.85	Carbon triple bonded to
157.43	Using microwave energy		nitrogen containing
157.44	Using ionizing radiation	157.86	Halogen containing
157.45	Boron, phosphorous or silicon	157.87	Carboxylic acid or derivative
155 46	containing product produced	155.00	product produced
157.46	Nitrogen containing product	157.88	Oxygen other than as part of
155 45	produced		a carboxylic acid or
157.47	Carbon containing product	157.89	derivative moiety
157 40	produced	137.69	Atom other than carbon,
157.48	Halogen containing product produced	157.9	hydrogen or oxygen
157.49	Sulfur containing product	157.91	Alcohol product producedFused or bridged ring
137.49	produced	137.91	containing
157.5	Oxygen containing product	157.92	Ether product produced
137.3	produced	157.93	Aldehyde or ketone product
157.51	Metal oxide or hydrate	137.73	produced
137.31	thereof	157.94	Halogen product produced
157.52	Hydrogen containing product	157.95	Carbon and halogen only in
137.32	produced	137.73	product
157.6	Process or preparing desired	157.96	Carbocyclic ring containing
137.0	organic product containing at	157.97	Aryl ring containing
	least one atom other than	157.98	Unsaturated product
	carbon and hydrogen	157.99	Unsaturation in aryl ring
157.61	Using laser	158.1	Carbocyclic ring containing
157.62	Using sonic or ultrasonic	158.11	Two or more diverse halogen
	energy	•	atoms containing
157.63	Using ionizing radiation		_

158.12	Four or more carbon atoms containing	461	With analysis or detailed detection
158.14	At least one carbocyclic ring	462	With posttreatment of gel to
130.14	and only carbon and hydrogen	402	purify or recover a desired
	atoms in product produced		component
158.2	Processes of purifying	463	Destaining
130.2	materials	464	Blotting
158.21	Organic material purified	465	_
130.21	Organic material purified	403	Preparation in unitary
Note: Se	ee subclasses 900-914 for art col-		<pre>apparatus (e.g., preparative, etc.)</pre>
	s pertaining to subclasses 157.15-	466	•
157.21.		467	Using slab gel
		468	Vertical or inclined
		469	Electrolyte composition
		469	Gel composition (other than simple agarose or
164	.Electrostatic field or		
104	electrical discharge	470	polyacrylamide)
165	3	470	Including manufacture or
166	Organic		<pre>preparation (e.g., molding, gelation, etc.)</pre>
167	Vitamins	471	Coating or forming of object
10/	Fats, fatty oils, ester type	472	
1.00	waxes, or higher fatty acids	4/2	With control responsive to sensed condition
168	Hydrocarbons	473	
169	Halogenated or oxidized	473 474	Temperature sensed
170	Gaseous	474 475	Current sensed
171	Acetylene	4/5	Rubber or vulcanizable gum used to coat or form
172	Cracking hydrocarbon oils	176	
173	Carbon	476	Sheet, web, wire, or filament
174	Sulfur-oxygen compounds		of indeterminant length formed or coated
175	Hydrogen peroxide	477	
176	Ozone	477 478	Alternating currentWith irradiation or
177	Nitrogen compounds	470	illumination (e.g., for
178	Arc or spark discharge		curing, etc.)
179	Nitrogen oxides	479	Coating interior of object
450	.Electrophoresis or electro-	480	With regeneration or
	osmosis processes and	400	replenishment of coating bath
	electrolyte compositions		(e.g., ultrafiltration, ion
	therefor when not provided for		exchange, measurement followed
4 E 1	elsewhere		by addition of concentrated
451	Capillary electrophoresis With detailed detection		reagent, etc.)
452		481	Using ion exchange material
453	With injection	482	Using filter or membrane
454	With adjustment or alteration	483	Forming of object
455	of electro-osmotic bulk flow	484	Plural coating operations
455	Using gel-filled capillary	485	Using mask
456	Gel electrophoresis	486	Including nonelectrophoretic
457	With programmed, cylic, or	100	coating
450	time responsive control	487	With heat treatment of a
458	Plural rapid changes in	10.	coated layer (e.g., curing,
	direction of electric field		sintering, etc.)
	(at least 1,000 times total and at more than 1/sec) (e.g.,	488	Organic (e.g., curing
	pulsed field, etc.)		thermoset resin, etc.)
459	Isoelectric focusing (i.e.,	489	Using bath having designated
100	using pH variation)		chemical composition (DCC)
	abiling pil variacioni,		,

490	Resultant coating is solely inorganic	516	Barrier separation (e.g., using membrane, filter paper,
491	With heat treatment of	E 1 B	etc.)
	coating	517	Ion selective
492	Anodic processes only	518	Barrier separation (e.g., using
493	With heat treatment of		membrane, filter paper, etc.)
	coating	519	With control responsive to
494	And washing, rinsing, or		sensed condition
	drying of coating	520	Ion selective
495	With pretreatment of	521	Combined with manufacture or
	substrate or bath		pretreatment of barrier
496	Bath contains shading or	522	Using both anion and cation
	coloring agent (e.g., pigment,		selective membranes
	etc.)	523	Alternating anion and cation
497	Bath contains surface active		selective membranes
	agent (e.g., soap or	524	And using ion exchange
	detergent, wetting or		material (e.g., suspended
	emulsifying agent, etc.)		particles, etc.)
498	Bath contains carboxyl group	525	With prevention of scale
499	Cathodic processes only		buildup or fouling of membrane
500	With heat treatment of	526	Gas or vapor treated
	coating	527	Biological material
501	Bath contains epoxy or		prepared, recovered, or
	epoxide		<pre>treated (e.g., urine, etc.)</pre>
502	Bath contains epoxy or	528	Regeneration of liquid
	epoxide		electrolyte
503	And shading or coloring	529	Metal or metal salt
	agent		recovered or removed
504	And separate crosslinking	530	Organic material prepared,
	or curing agent		recovered, or treated
505	Isocyanate	531	Acid prepared, recovered,
506	Bath contains separate		or treated
	crosslinking or curing agent	532	And using nonion selective
507	With posttreatment of coating		membrane
	(e.g., heat treatment,	533	And using ion exchange
	washing, drying, etc.)		material (e.g., suspended
508	Bath contains shading or		particles, etc.)
	coloring agent, metal oxide,	534	And using bipolar membrane
	free metal, or free carbon	535	And using nonion selective
509	With heat treatment of coating		membrane
510	With pretreatment of substrate	536	And using ion exchange
	(e.g., cleaning, wetting,		material (e.g., suspended
	etc.)		particles, etc.)
511	Using liquid jet	537	Using bipolar membrane
512	Continuous movement of	538	Water splitting
	substrate through bath	539	Using anion selective
513	Hydrocarbon oil separated or		membrane
	purified	540	Biological material prepared,
514	Aqueous system		recovered, or treated (e.g.,
515	Inorganic siliceous or		urine, etc.)
	calcareous material prepared,	541	Organic material prepared,
	separated, or treated (e.g.,		recovered, or treated
	clay, earth, concrete,		
	asbestos, glass, etc.)		

542	Combined with diverse-type	565	Using modified alternating
	separation (e.g., electro-		current (other than standard
	osmotic barrier separation		50 Hz or 60 Hz sine wave) field
	combined with centrifugal	567	Using modifying agent
	separation, etc.)	568	Gas or vapor
543	Biological material prepared,		
343		569	Dielectric liquid
	recovered, or treated (e.g.,	570	Water
	urine, etc.)	571	Removing solids
544	Organic material prepared,	572	Using cohesive filter or solid
	recovered, or treated		packing
545	With use of nonelectrical field	573	Resolving emulsion or
	or force to separate (e.g.,		dispersion
	magnetic, centrifugal, etc.)	192.1	.Coating, forming or etching by
546	Absorbent strip electrophoresis	192.1	
5 1 0	(e.g., using cellulose acetate	100 11	sputtering
	or paper strip, etc.)	192.11	Ion beam sputter deposition
E 4 7		192.12	Glow discharge sputter
547	Dielectrophoresis (i.e., using		deposition (e.g., cathode
	nonuniform electric field)		sputtering, etc.)
548	Isoelectric focusing (i.e.,	192.13	Measuring or testing (e.g., of
	using pH variation)		operating parameters, property
549	Isotachophoresis (i.e.,		of article, etc.)
	displacement electrophoresis)	192.14	Coating inorganic material
	or measurement of ion or	172.14	
	particle mobility	100 15	onto polymeric material
550	Ionophoresis	192.15	Specified deposition material
551	-		or use
	Solid sorption or desorption	192.16	Wear or abrasion resistant
553	Bulk separation of solids and	192.17	Electrical contact material
	liquids (e.g., dewatering	192.18	Piezoelectric
	solids, clarifying water,	192.2	Ferromagnetic
	etc.)	192.21	Resistor
554	.Electrical (including	192.22	Insulator or dielectric
	simultaneous electrical and	192.23	
	magnetic) separation or		Silicon containing
	purification of liquid or	192.24	Superconductor
	magnetic treatment of liquid	192.25	Semiconductor
	(other than separation)	192.26	Optical or photoactive
555	With control responsive to	192.27	Reflective
333	sensed condition	192.28	Absorptive
ГГС		192.29	Transparent conductor
556	With measuring, testing, or	192.3	With sputter etching
	sensing	192.32	Sputter etching
557	Using magnetic field		_
558	With simultaneous use of	192.33	Measuring or testing (e.g., of
	liquid-liquid extraction		operating parameters, end
	solvent		<pre>point determination, etc.)</pre>
559	Predominantly hydrocarbon	192.34	Ion beam etching (e.g., ion
560	Removing solids		milling, etc.)
561	With addition of agent to	192.35	Etching specified material
301	facilitate removal	192.36	Organic
F.C.2		192.37	Silicon containing
562	Using cohesive filter or	192.38	.Vacuum arc discharge coating
	solid packing		
563	Resolving emulsion or	193	APPARATUS
	dispersion	194	.Electrolytic
564	Using interrupted or pulsed	400	Analysis and testing
	direct current field	401	Fault testing of sensor or
			component

400	Domanauskian au askiroskian	110	Outron i a mambasana
402	Regeneration or activation	418	Organic membrane
403.01	Biological material (e.g.,	419	Inorganic membrane
	microbe, enzyme, antigen,	420	Glass ion-selective membrane
	etc.) analyzed, tested, or	421	Solid electrolyte
402 00	included in apparatus	422	Liquid sample sensor
403.02	Disposable apparatus or	423	With fugitive protective
	apparatus having removable		element
	section (e.g., removable	424	Gas sample sensor
402 02	cartridge, etc.)	425	With impressed current means
403.03	Plural measuring sections or	426	Planar electrode surface
402 04	zones	427	With gas reference material
403.04	Enzyme included in apparatus	428	With protective element
403.05	With semipermeable membrane	429	Protective element is a
403.06	With semipermeable membrane		layer
403.07	For blocking passage of	430	Moisture absorbing electrolyte
	macromolecules (molecular	431	Gas sensing electrode
	weight greater than or equal	432	With gas diffusion electrode
400 00	to 8,000)	433	Measuring carbon or pH
403.08	Lipid included in apparatus	434	Involving plating, coating or
403.09	Enzyme included in		stripping
400 4	apparatus	435	Standard reference electrode
403.1	Enzyme included in apparatus	196.01	Object protection
403.11	Glucose oxidase	196.02	With control means responsive
403.12	With diverse enzyme or		to sensed condition
	catalyst (e.g., bienzyme or	196.03	And programmed, cyclic, or
	coenzyme system, glucose		time responsive control means
	oxidase with Pt catalyst,	196.04	Internal battery
402 12	etc.)	196.05	With programmed, cyclic, or
403.13	And microelectrode (i.e., at		time responsive control means
	least one electrode dimension is less than 500 microns)	196.06	With measuring, testing, or
403.14	•		sensing means
	Enzyme included in apparatus	196.07	Internal battery
403.15	Electrode containing free carbon	196.08	With gas or vapor removing or
404			treating means
404	Corrosion	196.09	Plural cells used or protected
405	Titration	196.1	Internal battery
406	With significant electrical	196.11	Resistor or impedance in
	circuitry or nominal computer		series between anode and
407	device		object
407	With significant display or	196.12	With fluid filter
400	analytical device	196.13	With bypass means
408	With means for temperature or	196.14	Anode moving relative to
400	pressure compensation		object
409	With means providing	196.15	With fluid inlet or outlet
	specified-flow condition or		means used or protected
410	flow-path	196.16	Dielectric coating, casing,
410	Solid electrolyte means		or section
411	Three or more electrodes	196.17	Rigid anode with rigid
412	Three or more electrodes	— .	support
413	Liquid electrode, e.g., Hg,	196.18	More than half of anode is
111	Na, etc.		or has coating, covering, or
414	Gel electrolyte		shield
415	Selectively permeable membrane	196.19	Dielectric coating,
416	Ion-sensitive electrode		covering, or shield
417	Liquid ion-exchanger		-

196.2	Flexible cable, chain, or	214	Swinging or tilting
106 01	wire anode or support	015	receptacles
196.21	Earth grounded object or	215	With base treatment
	protection means	216	Stripping
196.22	Copper and zinc electrically	217	Mechanical working
	coupled or alloyed into one or	218	With current control
	more electrodes	219	Liquid electrode
196.23	Anode contains aluminum	220	With electrode recirculation
196.24	And magnesium		means
196.25	And zinc	221	With oscillator, reciprocator
196.26	Resistor or impedance in		or agitator
	series between power supply and object	222	Electrode oscillator, reciprocator or agitator
196.27	Alternative energy supply	223	With current control
	(e.g., solar panel,	224 R	Localized area applicators
	thermoelectric or	224 M	Electrochemical machining
	piezoelectric power supply,	225	Electrode feeding or
	etc.)	223	withdrawal means
196.28	Rotating electrode	226	With base treatment
196.29	Magnetic mounting means	227	Cells with base treatment means
196.3	Rigid anode with rigid support	228.1	With current, voltage, or power
196.31	Threaded coupling for rigid	220.1	control means responsive to
	anode or rigid support		sensed condition
196.32	Dielectric thread	228.2	Fluid level sensing means
196.33	Flexible cable, chain, or wire	228.3	Fluid flow sensing means
	anode or support	228.4	Fluid pressure sensing means
196.34	Plural anode sections on	228.5	Gaseous fluid
	single cable, chain, or wire	228.6	Electrolyte property sensing
196.35	Helically wound	220.0	
196.36	Earth grounded object or		<pre>means (e.g., temperature, concentration, pH,</pre>
	protection means		conductivity, etc.)
196.37	Vessel protected (e.g., steam	228.7	Workpiece property sensing
	boiler, etc.)	220.7	means (e.g., mass, coating
196.38	Anode contains precious metal		thickness, etc.)
	or free carbon	228.8	Workpiece presence, position,
	With movable electrode means	220.0	or movement sensing means
198	Work conveyer	228.9	Having auxiliary electrode
199	Rotary	220.9	Reference electrode as or
200	With base treatment	229.1	with auxiliary electrode
201	Loose article	229.2	And programmed, cyclic, or
202	Endless	229.2	time responsive control means
202	With base treatment	229.3	
203	With base treatmentWith current control	229.3	For controlling waveform
204	With current control	220 4	supplied to working electrode
205	Continuous strip or filament	229.4	With programmed, cyclic, or
206	electrode		time responsive current, voltage, or power control
207	With base treatment		means
208	Stripping	229.5	For controlling waveform
209	Mechanical working		supplied to working electrode
210	Heat treatment means	229.6	For simultaneously reversing
211	With current control		polarity of working and
212	Rotary		counter electrodes
213	Barrels and rotary	229.7	Having specified circuit
	receptacles		details

229.8	With means for measuring, testing, or sensing current,	257	With feeding and/or withdrawal means
	voltage, or power	258	Gas
229.9	Having auxiliary electrode	259	Basket-type electrode
230.1	Reference electrode as or with auxiliary electrode	260	Concentrically arranged electrodes
230.2	With current, voltage, or power	261	With agitator
250.2	control means	262	With heater or cooler
230.3	Mechanical	263	With feeding and/or
230.4	For inhibiting short circuits	203	withdrawal means
230.4	Switch or connector	264	And filter
230.5	For controlling waveform	265	
230.7			Gas feeding
230.7	Having auxiliary electrode	266	Gas withdrawal
230.8	Having specified circuit	267	Plural cells
222	details	268	Bipolar electrode
232	Cells with electrolyte	269	With feeding and/or
022	treatment means	0.7.0	withdrawal means
233	Leacher, dissolver or	270	Gas
004	extractor	271	Portable
234	Recirculation	272	Concentrically arranged
235	With filter		electrodes
236	With heater or cooler	273	With agitator
237	Recirculation	274	With heater or cooler
238	With filter	275.1	With feeding and/or withdrawal
239	With heater or cooler		means
240	With filter	[0 +]-	Grand Nation for EOD Gallantian
241	With heater or cooler	=	e Search Notes for FOR Collections ted with this subclass or its
242	Q - 1 1 -:		
	Cells		
243.1	Fused bath		(if there are indents).]
243.1 244			
243.1	Fused bath		
243.1 244	Fused bathPlural cells	indents	(if there are indents).]
243.1 244	<pre>Fused bathPlural cellsWith feeding and/or</pre>	indents	<pre>(if there are indents).]And filter</pre>
243.1 244 245	<pre>Fused bathPlural cellsWith feeding and/or withdrawal means</pre>	indents 276 277	(if there are indents).]
243.1 244 245 246	Fused bathPlural cellsWith feeding and/or withdrawal meansGas feeding	indents 276 277 278	<pre>(if there are indents).]And filter</pre>
243.1 244 245 246 247	Fused bathPlural cellsWith feeding and/or withdrawal meansGas feedingGas withdrawal	indents 276 277	<pre>(if there are indents).]And filterGas feeding</pre>
243.1 244 245 246 247	Fused bathPlural cellsWith feeding and/or withdrawal meansGas feedingGas withdrawalWith magnetic field effect	indents 276 277 278	<pre>(if there are indents).]And filterGas feedingGas withdrawal</pre>
243.1 244 245 246 247 247.1 247.2	Fused bathPlural cellsWith feeding and/or withdrawal meansGas feedingGas withdrawalWith magnetic field effect compensating meansWith means for cleaning electrode element	276 277 278 278.5	<pre>(if there are indents).]And filterGas feedingGas withdrawalParallel plate type electrodesElements</pre>
243.1 244 245 246 247 247.1	Fused bathPlural cellsWith feeding and/or withdrawal meansGas feedingGas withdrawalWith magnetic field effect compensating meansWith means for cleaning	276 277 278 278.5	<pre>(if there are indents).]And filterGas feedingGas withdrawalParallel plate type electrodes</pre>
243.1 244 245 246 247 247.1 247.2	Fused bathPlural cellsWith feeding and/or withdrawal meansGas feedingGas withdrawalWith magnetic field effect compensating meansWith means for cleaning electrode element	276 277 278 278.5	<pre>(if there are indents).]And filterGas feedingGas withdrawalParallel plate type electrodesElements</pre>
243.1 244 245 246 247 247.1 247.2	Fused bathPlural cellsWith feeding and/or withdrawal meansGas feedingGas withdrawalWith magnetic field effect compensating meansWith means for cleaning electrode elementRefractory hard material	276 277 278 278.5 279 280	<pre>(if there are indents).]And filterGas feedingGas withdrawalParallel plate type electrodesElementsElectrodes</pre>
243.1 244 245 246 247 247.1 247.2 247.3	Fused bathPlural cellsWith feeding and/or withdrawal meansGas feedingGas withdrawalWith magnetic field effect compensating meansWith means for cleaning electrode elementRefractory hard material (RHM) containing electrode	276 277 278 278.5 279 280	<pre>(if there are indents).]And filterGas feedingGas withdrawalParallel plate type electrodesElectrodesElectroforming molds or</pre>
243.1 244 245 246 247 247.1 247.2 247.3	Fused bathPlural cellsWith feeding and/or withdrawal meansGas feedingGas withdrawalWith magnetic field effect compensating meansWith means for cleaning electrode elementRefractory hard material (RHM) containing electrodeWith cell lining or coating	276 277 278 278.5 279 280 281	<pre>(if there are indents).]And filterGas feedingGas withdrawalParallel plate type electrodesElectrodesElectroforming molds or strips plates</pre>
243.1 244 245 246 247 247.1 247.2 247.3	Fused bathPlural cellsWith feeding and/or withdrawal meansGas feedingGas withdrawalWith magnetic field effect compensating meansWith means for cleaning electrode elementRefractory hard material (RHM) containing electrodeWith cell lining or coatingThermal effect compensating	276 277 278 278.5 279 280 281	<pre>(if there are indents).] And filterGas feedingGas withdrawalParallel plate type electrodesElementsElectroforming molds or strips platesWith diaphragm</pre>
243.1 244 245 246 247 247.1 247.2 247.3 247.4 247.5	Fused bathPlural cellsWith feeding and/or withdrawal meansGas feedingGas withdrawalWith magnetic field effect compensating meansWith means for cleaning electrode elementRefractory hard material (RHM) containing electrodeWith cell lining or coatingThermal effect compensating means	276 277 278 278.5 279 280 281	<pre>(if there are indents).]And filterGas feedingGas withdrawalParallel plate type electrodesElectrodesElectroforming molds or strips platesWith diaphragmPerforated or foraminous</pre>
243.1 244 245 246 247 247.1 247.2 247.3 247.4 247.5	Fused bathPlural cellsWith feeding and/or withdrawal meansGas feedingGas withdrawalWith magnetic field effect compensating meansWith means for cleaning electrode elementRefractory hard material (RHM) containing electrodeWith cell lining or coatingThermal effect compensating meansInternal battery	276 277 278 278.5 279 280 281 282 283	<pre>(if there are indents).] And filterGas feedingGas withdrawalParallel plate type electrodesElementsElectrodesElectroforming molds or strips platesWith diaphragmPerforated or foraminous electrode</pre>
243.1 244 245 246 247 247.1 247.2 247.3 247.4 247.5	Fused bathPlural cellsWith feeding and/or withdrawal meansGas feedingGas withdrawalWith magnetic field effect compensating meansWith means for cleaning electrode elementRefractory hard material (RHM) containing electrodeWith cell lining or coatingThermal effect compensating meansInternal batteryFilter or loose electrode	276 277 278 278.5 279 280 281 282 283	<pre>(if there are indents).]And filterGas feedingGas withdrawalParallel plate type electrodesElectrodesElectroforming molds or strips platesWith diaphragmPerforated or foraminous electrodePerforated or foraminous</pre>
243.1 244 245 246 247 247.1 247.2 247.3 247.4 247.5	Fused bathPlural cellsWith feeding and/or withdrawal meansGas feedingGas withdrawalWith magnetic field effect compensating meansWith means for cleaning electrode elementRefractory hard material (RHM) containing electrodeWith cell lining or coatingThermal effect compensating meansInternal batteryFilter or loose electrode type	276 277 278 278.5 279 280 281 282 283	<pre>(if there are indents).] And filterGas feedingGas withdrawalParallel plate type electrodesElectrodesElectroforming molds or strips platesWith diaphragmPerforated or foraminous electrodePerforated or foraminousPerforated or foraminous</pre>
243.1 244 245 246 247 247.1 247.2 247.3 247.4 247.5 248 249	Fused bathPlural cellsWith feeding and/or withdrawal meansGas feedingGas withdrawalWith magnetic field effect compensating meansWith means for cleaning electrode elementRefractory hard material (RHM) containing electrodeWith cell lining or coatingThermal effect compensating meansInternal batteryFilter or loose electrode typeLiquid electrode	276 277 278 278.5 279 280 281 282 283 284 285 286.1	<pre>(if there are indents).] And filterGas feedingGas withdrawalParallel plate type electrodesElectrodesElectroforming molds or strips platesWith diaphragmPerforated or foraminous electrodePerforated or foraminous electrodePerforated or supporting means</pre>
243.1 244 245 246 247 247.1 247.2 247.3 247.4 247.5 248 249	Fused bathPlural cellsWith feeding and/or withdrawal meansGas feedingGas withdrawalWith magnetic field effect compensating meansWith means for cleaning electrode elementRefractory hard material (RHM) containing electrodeWith cell lining or coatingThermal effect compensating meansInternal batteryFilter or loose electrode typeLiquid electrodeDiaphragm type	276 277 278 278.5 279 280 281 282 283 284 285 286.1	<pre>(if there are indents).] And filterGas feedingGas withdrawalParallel plate type electrodesElectrodesElectroforming molds or strips platesWith diaphragmPerforated or foraminous electrodePerforated or foraminous electrodePerforated or foraminousWork holderWith electrode supporting means</pre>
243.1 244 245 246 247 247.1 247.2 247.3 247.4 247.5 248 249 250 251 252	Fused bathPlural cellsWith feeding and/or withdrawal meansGas feedingGas withdrawalWith magnetic field effect compensating meansWith means for cleaning electrode elementRefractory hard material (RHM) containing electrodeWith cell lining or coatingThermal effect compensating meansInternal batteryFilter or loose electrode typeLiquid electrodeDiaphragm typeDiaphragm type	276 277 278 278.5 279 280 281 282 283 284 285 286.1	<pre>(if there are indents).] And filterGas feedingGas withdrawalParallel plate type electrodesElectrodesElectroforming molds or strips platesWith diaphragmPerforated or foraminous electrodePerforated or foraminous electrodeWork holderWith electrode supporting means e Search Notes for FOR Collections ted with this subclass or its</pre>
243.1 244 245 246 247 247.1 247.2 247.3 247.4 247.5 248 249 250 251 252 253	Fused bathPlural cellsWith feeding and/or withdrawal meansGas feedingGas withdrawalWith magnetic field effect compensating meansWith means for cleaning electrode elementRefractory hard material (RHM) containing electrodeWith cell lining or coatingThermal effect compensating meansInternal batteryFilter or loose electrode typeLiquid electrodeDiaphragm typeDiaphragm typePlural cells	276 277 278 278.5 279 280 281 282 283 284 285 286.1	<pre>(if there are indents).] And filterGas feedingGas withdrawalParallel plate type electrodesElectrodesElectroforming molds or strips platesWith diaphragmPerforated or foraminous electrodePerforated or foraminous electrodePerforated or foraminousWork holderWith electrode supporting means</pre>
243.1 244 245 246 247 247.1 247.2 247.3 247.4 247.5 248 249 250 251 252 253 254	Fused bathPlural cellsWith feeding and/or withdrawal meansGas feedingGas withdrawalWith magnetic field effect compensating meansWith means for cleaning electrode elementRefractory hard material (RHM) containing electrodeWith cell lining or coatingThermal effect compensating meansInternal batteryFilter or loose electrode typeLiquid electrodeDiaphragm typeDiaphragm typePlural cellsBipolar electrode	276 277 278 278.5 279 280 281 282 283 284 285 286.1	<pre>(if there are indents).] And filterGas feedingGas withdrawalParallel plate type electrodesElectrodesElectroforming molds or strips platesWith diaphragmPerforated or foraminous electrodePerforated or foraminous electrodeWork holderWith electrode supporting means e Search Notes for FOR Collections ted with this subclass or its</pre>
243.1 244 245 246 247 247.1 247.2 247.3 247.4 247.5 248 249 250 251 252 253 254	Fused bathPlural cellsWith feeding and/or withdrawal meansGas feedingGas withdrawalWith magnetic field effect compensating meansWith means for cleaning electrode elementRefractory hard material (RHM) containing electrodeWith cell lining or coatingThermal effect compensating meansInternal batteryFilter or loose electrode typeLiquid electrodeDiaphragm typeDiaphragm typeDiaphragm typePlural cellsBipolar electrodeWith feeding and/or	276 277 278 278.5 279 280 281 282 283 284 285 286.1	<pre>(if there are indents).] And filterGas feedingGas withdrawalParallel plate type electrodesElectrodesElectroforming molds or strips platesWith diaphragmPerforated or foraminous electrodePerforated or foraminous electrodeWork holderWith electrode supporting means e Search Notes for FOR Collections ted with this subclass or its</pre>

287 288	Work containerElectrodes with lateral extensions	290.14	Noble metal (i.e., Ru, Rh, Pd, Os, Ir, Pt, Ag, or Au) or compound containing
288.1	And dielectric gasket or spacer	290.15 291	Free carbon containingComposition
288.2	And additional electrical conductor of diverse material	292 293	Metallic Alloys
288.3	<pre>Including resilient means (e.g., spring, etc.)</pre>	294 295	Carbon containingDiaphragms
288.4 288.5	Including threaded connectorHaving wedge or tapered tightening means	296 297.01	OrganicElectrode support or work holder
288.6 289 290.01	Hook or loopWith lateral extensionsLaminated or coated (i.e., composite having two or more layers)	associat	Search Notes for FOR Collections ed with this subclass or its)if there are indents).]
•	Search Notes for FOR Collections ed with this subclass or its	297.02	Magnatia guppant
indents	(if there are indents).]	297.02	Magnetic supportVacuum support
		297.04	Float or buoyant support
		297.05	Mask for workpiece
		297.06	Workpiece rack
290.02	Actinide series element	297.07	Adjustable
	(i.e., Ac, Th, Pa, U, Np, Pu,	297.08	Mechanized
	Am, Cm, Bk, Cf, Es, Fm, Md, No, or Lr) or compound containing	297.09	Including resilient means
290.03	Having three or more layers	297.1	<pre>(e.g., spring, etc.)Including resilient means</pre>
290.04	Rare earth metal (i.e., Sc,	201.1	(e.g., spring, etc.)
	Y, La, Ce, Pr, Nd, Pm, Sm, Eu,	297.11	Porous enclosure
	Gd, Tb, Dy, Ho, Er, Tm, Yb, or	297.12	Grid or grating
200 05	Lu) or compound containing	297.13	Including threaded connector
290.05 290.06	Organic compound containingAnd noble metal (i.e., Ru,	297.14	<pre>Including resilient means (e.g., spring, etc.)</pre>
	Rh, Pd, Os, Ir, Pt, Ag, or Au)	297.15	Including threaded connector
	or compound containing	297.16	Hook or loop
290.07	And free carbon containing	298.01	.Coating, forming or etching by
290.08	Noble metal (i.e., Ru, Rh,		sputtering
	Pd, Os, Ir, Pt, Ag, or Au) or compound containing	298.02	Coating
290.09	Plural metal oxides	298.03	Measuring, analyzing or
200.00	containing		testing
290.1	Rare earth metal (i.e., Sc,	298.04	Ion beam sputter deposition
	Y, La, Ce, Pr, Nd, Pm, Sm, Eu,	298.05	Ion plating
	Gd, Tb, Dy, Ho, Er, Tm, Yb, or	298.06	Triode, tetrode, auxiliary
290.11	Lu) or compound containingOrganic compound containing	298.07	electrode or biased workpieceSpecified gas feed or
290.12	Refractory metal (i.e., Ti,	000 00	withdrawal
	V, Cr, Zr, Nb or Cb, Mo, Hf, Ta, or W) or compound	298.08	Specified power supply or matching network
	containing	298.09	Specified cooling or heating
290.13	Surface layer contains	298.11	Specified mask, shield or shutter
	electrolytically exposed refractory metal or compound	298.12	Specified target particulars

298.13	Target composition	603	With detailed detection system
298.14	Specified anode particulars		(e.g., including a light
298.15	Specified work holder		source and a camera, etc.)
298.16	Magnetically enhanced	604	With injector
298.17	Flux passes through target	605	Gel filled
	surface	606	Gel electrophoresis type
298.18	Focusing target (e.g.,	607	With control means responsive
	conical target, plural		to sensed condition
	inclined targets, etc.)	608	With programmed, cyclic, or
298.19	Planar magnetron		time responsive control means
298.2	Moving magnetic field or	609	Plural rapid changes in
	target		direction of electric field
298.21	Cylindrical or curved		(at least 1,000 times total
	magnetron target		and at more than 1/sec) (e.g.,
298.22	Moving magnetic field or		<pre>pulsed field, etc.)</pre>
	target	610	Isoelectric focusing (i.e.,
298.23	Moving workpiece or target		uses pH variation)
298.24	Indeterminate length moving	612	With detailed detection system
270.21	workpiece		(e.g., including a light
298.25	Multi-chamber (e.g.,		source and a camera, etc.)
200.25	including air lock, load/	613	With means for posttreatment
	unload chamber, etc.)		of gel to purify or recover a
298.26	Plural diverse treatment		desired component
200.20	stations, zones, or coating	614	Blotter (e.g., membrane,
	material source within single		etc.)
	chamber	615	Unitary preparation apparatus
298.27	Plural modes of movement		(e.g., preparative means,
200.27	(e.g., planetary, epicyclic,		etc.)
	etc.)	616	Slab gel
298.28	Rotational movement	617	Curved
298.29	Oscillatory movement	618	Vertical or inclined
298.31	oscillatory movement	619	With gel shaping or molding
298.31	3	019	means (e.g., comb, ribbed
290.32	<pre>Measuring, analyzing or testing</pre>		insert, gel injectors, etc.)
298.33	_	620	With gel shaping or molding
490.33	Specified gas feed or withdrawal	020	means (e.g., comb, ribbed
200 24			insert, gel injectors, etc.)
298.34	Auxiliary electrode, bias	621	With liquid heat exchange
	means or specified power	021	means to cool gel slab during
200 25	supply		electrophoresis
298.35	Multi-chamber, load/unload	622	Coating or forming means
222	means or moving workpiece	623	With moving or movable
298.36	Beam or directed flux etching	023	electrode
	(e.g., ion beam, etc.)	C 2 4	
298.37	Magnetically enhanced	624	And means for posttreatment
298.38	Microwave excitation		of coating (e.g., drying,
298.39	Plural parallel plates (e.g.,	625	heating, curing, etc.)
	desmearing reactor, etc.)	025	Coating interior of object or
298.41	.Vacuum arc discharge coating		article (e.g., water main,
600	.Electrophoretic or electro-	626	automobile body, etc.)
	osmotic apparatus	626	With means for regeneration or
601	Capillary electrophoresis type		replenishment of coating bath
602	With control means responsive	627	or electrolyte
	to sensed condition	627	Barrier separator (e.g.,
			electrodialyzer, etc.)

628	With control means responsive	660	.Apparatus for electrical
	to sensed condition		(including simultaneous
629	With moving or movable		electrical and magnetic)
	electrode		separation or purification of
630	Ion selective		liquid or magnetic treatment
631	With bipolar membrane		of liquid (other than
632	And ion exchange material		separation)
	(e.g., suspended ion exchange	661	With control means responsive
	resin particles, etc.)		to sensed condition
633	Both anion and cation	662	Liquid level sensing means
	selective membranes	663	With programmed, cyclic, or
634	\ldots .Alternating anion and cation		time responsive control means
	selective membranes	664	With magnetic separating means
635	Tortuous path-type frame or	665	With filter (e.g.,
	membrane spacer		electrostatic filter, etc.)
636	With foraminous or	666	Plural separate treatment
	perforated membrane support or	668	chambers or zones
	spacer (e.g., screen,	667	Probe type
	perforated plate, fabric,	668	With moving or movable
	etc.)	660	electrode
637	And nonion selective membrane	669	Rotating or rotatable
638	With foraminous or perforated	670	Concentric electrodes
	membrane support or spacer	671	Cylindrical or annular
	(e.g., screen, perforated	672	Parallel plate-type electrodes
639	plate, fabric, etc.)	673	Vertical flat plates
039	With foraminous or perforated	674	Porous, perforated, or grid
	<pre>membrane support or spacer (e.g., screen, perforated</pre>		electrode
	(e.g., Screen, periorated		
640	<pre>plate, fabric, etc.)</pre>		
640	<pre>plate, fabric, etc.)Cylindrical barrier (e.g.,</pre>		
	<pre>plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)</pre>	CROSS-1	REFERENCE ART COLLECTIONS
640 641	<pre>plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)Absorbent strip (e.g.,</pre>		_
	<pre>plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)Absorbent strip (e.g., cellulose acetate, paper</pre>	CROSS-1	EFFECTING A CHANGE IN
	<pre>plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)Absorbent strip (e.g., cellulose acetate, paper strip, etc.) type</pre>	900	EFFECTING A CHANGE IN ISOMERIZATION BY WAVE ENERGY
641	<pre>plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)Absorbent strip (e.g., cellulose acetate, paper strip, etc.) typeMovable strip</pre>		EFFECTING A CHANGE IN ISOMERIZATION BY WAVE ENERGY EFFECTING A COLOR CHANGE BY WAVE
641	<pre>plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)Absorbent strip (e.g., cellulose acetate, paper strip, etc.) type</pre>	900	EFFECTING A CHANGE IN ISOMERIZATION BY WAVE ENERGY EFFECTING A COLOR CHANGE BY WAVE ENERGY
641	<pre>plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)Absorbent strip (e.g., cellulose acetate, paper strip, etc.) typeMovable stripDielectrophoretic (i.e., uses</pre>	900	EFFECTING A CHANGE IN ISOMERIZATION BY WAVE ENERGY EFFECTING A COLOR CHANGE BY WAVE ENERGY PRODUCTION OF DESIRED COMPOUND BY
641 642 643	<pre>plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)Absorbent strip (e.g., cellulose acetate, paper strip, etc.) typeMovable stripDielectrophoretic (i.e., uses nonuniform electric field)</pre>	900	EFFECTING A CHANGE IN ISOMERIZATION BY WAVE ENERGY EFFECTING A COLOR CHANGE BY WAVE ENERGY PRODUCTION OF DESIRED COMPOUND BY WAVE ENERGY IN PRESENCE OF A
641 642 643	<pre>plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)Absorbent strip (e.g., cellulose acetate, paper strip, etc.) typeMovable stripDielectrophoretic (i.e., uses nonuniform electric field)Isoelectric focusing (i.e.,</pre>	900	EFFECTING A CHANGE IN ISOMERIZATION BY WAVE ENERGY EFFECTING A COLOR CHANGE BY WAVE ENERGY PRODUCTION OF DESIRED COMPOUND BY WAVE ENERGY IN PRESENCE OF A CHEMICALLY DESIGNATED
641 642 643 644	<pre>plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)Absorbent strip (e.g., cellulose acetate, paper strip, etc.) typeMovable stripDielectrophoretic (i.e., uses nonuniform electric field)Isoelectric focusing (i.e., uses pH variation)</pre>	900	EFFECTING A CHANGE IN ISOMERIZATION BY WAVE ENERGY EFFECTING A COLOR CHANGE BY WAVE ENERGY PRODUCTION OF DESIRED COMPOUND BY WAVE ENERGY IN PRESENCE OF A CHEMICALLY DESIGNATED NONREACTANT CHEMICAL TREATING
641 642 643 644	<pre>plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)Absorbent strip (e.g., cellulose acetate, paper strip, etc.) typeMovable stripDielectrophoretic (i.e., uses nonuniform electric field)Isoelectric focusing (i.e., uses pH variation)Isotachophoretic (i.e.,</pre>	900	EFFECTING A CHANGE IN ISOMERIZATION BY WAVE ENERGY EFFECTING A COLOR CHANGE BY WAVE ENERGY PRODUCTION OF DESIRED COMPOUND BY WAVE ENERGY IN PRESENCE OF A CHEMICALLY DESIGNATED NONREACTANT CHEMICAL TREATING AGENT (EXCLUDING WATER,
641 642 643 644	<pre>plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)Absorbent strip (e.g., cellulose acetate, paper strip, etc.) typeMovable stripDielectrophoretic (i.e., uses nonuniform electric field)Isoelectric focusing (i.e., uses pH variation)Isotachophoretic (i.e., displacement electrophoretic)</pre>	900	EFFECTING A CHANGE IN ISOMERIZATION BY WAVE ENERGY EFFECTING A COLOR CHANGE BY WAVE ENERGY PRODUCTION OF DESIRED COMPOUND BY WAVE ENERGY IN PRESENCE OF A CHEMICALLY DESIGNATED NONREACTANT CHEMICAL TREATING AGENT (EXCLUDING WATER, CHLOROFORM, CARBON
641 642 643 644	<pre>plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)Absorbent strip (e.g., cellulose acetate, paper strip, etc.) typeMovable stripDielectrophoretic (i.e., uses nonuniform electric field)Isoelectric focusing (i.e., uses pH variation)Isotachophoretic (i.e., displacement electrophoretic) or means to measure ion or</pre>	900	EFFECTING A CHANGE IN ISOMERIZATION BY WAVE ENERGY EFFECTING A COLOR CHANGE BY WAVE ENERGY PRODUCTION OF DESIRED COMPOUND BY WAVE ENERGY IN PRESENCE OF A CHEMICALLY DESIGNATED NONREACTANT CHEMICAL TREATING AGENT (EXCLUDING WATER, CHLOROFORM, CARBON TETRACHLORIDE, METHYLENE
641 642 643 644 645	<pre>plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)Absorbent strip (e.g., cellulose acetate, paper strip, etc.) typeMovable stripDielectrophoretic (i.e., uses nonuniform electric field)Isoelectric focusing (i.e., uses pH variation)Isotachophoretic (i.e., displacement electrophoretic) or means to measure ion or particle mobility</pre>	900	EFFECTING A CHANGE IN ISOMERIZATION BY WAVE ENERGY EFFECTING A COLOR CHANGE BY WAVE ENERGY PRODUCTION OF DESIRED COMPOUND BY WAVE ENERGY IN PRESENCE OF A CHEMICALLY DESIGNATED NONREACTANT CHEMICAL TREATING AGENT (EXCLUDING WATER, CHLOROFORM, CARBON
641 642 643 644 645	<pre>plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)Absorbent strip (e.g., cellulose acetate, paper strip, etc.) typeMovable stripDielectrophoretic (i.e., uses nonuniform electric field)Isoelectric focusing (i.e., uses pH variation)Isotachophoretic (i.e., displacement electrophoretic) or means to measure ion or particle mobilityParticle bed separator (e.g., inert particles, ion exchange beads, etc.)</pre>	900 901 902	EFFECTING A CHANGE IN ISOMERIZATION BY WAVE ENERGY EFFECTING A COLOR CHANGE BY WAVE ENERGY PRODUCTION OF DESIRED COMPOUND BY WAVE ENERGY IN PRESENCE OF A CHEMICALLY DESIGNATED NONREACTANT CHEMICAL TREATING AGENT (EXCLUDING WATER, CHLOROFORM, CARBON TETRACHLORIDE, METHYLENE CHLORIDE OR BENZENE)
641 642 643 644 645	plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)Absorbent strip (e.g., cellulose acetate, paper strip, etc.) typeMovable stripDielectrophoretic (i.e., uses nonuniform electric field)Isoelectric focusing (i.e., uses pH variation)Isotachophoretic (i.e., displacement electrophoretic) or means to measure ion or particle mobilityParticle bed separator (e.g., inert particles, ion exchange beads, etc.)Bulk separator for solids and	900 901 902	EFFECTING A CHANGE IN ISOMERIZATION BY WAVE ENERGY EFFECTING A COLOR CHANGE BY WAVE ENERGY PRODUCTION OF DESIRED COMPOUND BY WAVE ENERGY IN PRESENCE OF A CHEMICALLY DESIGNATED NONREACTANT CHEMICAL TREATING AGENT (EXCLUDING WATER, CHLOROFORM, CARBON TETRACHLORIDE, METHYLENE CHLORIDE OR BENZENE) .Inorganic chemical treating
641 642 643 644 645	plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)Absorbent strip (e.g., cellulose acetate, paper strip, etc.) typeMovable stripDielectrophoretic (i.e., uses nonuniform electric field)Isoelectric focusing (i.e., uses pH variation)Isotachophoretic (i.e., displacement electrophoretic) or means to measure ion or particle mobilityParticle bed separator (e.g., inert particles, ion exchange beads, etc.)Bulk separator for solids and liquids (e.g., to dewater	900 901 902	EFFECTING A CHANGE IN ISOMERIZATION BY WAVE ENERGY EFFECTING A COLOR CHANGE BY WAVE ENERGY PRODUCTION OF DESIRED COMPOUND BY WAVE ENERGY IN PRESENCE OF A CHEMICALLY DESIGNATED NONREACTANT CHEMICAL TREATING AGENT (EXCLUDING WATER, CHLOROFORM, CARBON TETRACHLORIDE, METHYLENE CHLORIDE OR BENZENE) .Inorganic chemical treating agent
641642643644645647648	<pre>plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)Absorbent strip (e.g., cellulose acetate, paper strip, etc.) typeMovable stripDielectrophoretic (i.e., uses nonuniform electric field)Isoelectric focusing (i.e., uses pH variation)Isotachophoretic (i.e., displacement electrophoretic) or means to measure ion or particle mobilityParticle bed separator (e.g., inert particles, ion exchange beads, etc.)Bulk separator for solids and liquids (e.g., to dewater solids, clarify water, etc.)</pre>	900 901 902 903 904	EFFECTING A CHANGE IN ISOMERIZATION BY WAVE ENERGY EFFECTING A COLOR CHANGE BY WAVE ENERGY PRODUCTION OF DESIRED COMPOUND BY WAVE ENERGY IN PRESENCE OF A CHEMICALLY DESIGNATED NONREACTANT CHEMICAL TREATING AGENT (EXCLUDING WATER, CHLOROFORM, CARBON TETRACHLORIDE, METHYLENE CHLORIDE OR BENZENE) .Inorganic chemical treating agentMetal treating agent
641 642 643 644 645	<pre>plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)Absorbent strip (e.g., cellulose acetate, paper strip, etc.) typeMovable stripDielectrophoretic (i.e., uses nonuniform electric field)Isoelectric focusing (i.e., uses pH variation)Isotachophoretic (i.e., displacement electrophoretic) or means to measure ion or particle mobilityParticle bed separator (e.g., inert particles, ion exchange beads, etc.)Bulk separator for solids and liquids (e.g., to dewater solids, clarify water, etc.)With moving or movable</pre>	900 901 902 903 904 905	EFFECTING A CHANGE IN ISOMERIZATION BY WAVE ENERGY EFFECTING A COLOR CHANGE BY WAVE ENERGY PRODUCTION OF DESIRED COMPOUND BY WAVE ENERGY IN PRESENCE OF A CHEMICALLY DESIGNATED NONREACTANT CHEMICAL TREATING AGENT (EXCLUDING WATER, CHLOROFORM, CARBON TETRACHLORIDE, METHYLENE CHLORIDE OR BENZENE) .Inorganic chemical treating agentMetal treating agentHeavy metal agent
641642643644645647648649	plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)Absorbent strip (e.g., cellulose acetate, paper strip, etc.) typeMovable stripDielectrophoretic (i.e., uses nonuniform electric field)Isoelectric focusing (i.e., uses pH variation)Isotachophoretic (i.e., displacement electrophoretic) or means to measure ion or particle mobilityParticle bed separator (e.g., inert particles, ion exchange beads, etc.)Bulk separator for solids and liquids (e.g., to dewater solids, clarify water, etc.)With moving or movable electrode	900 901 902 903 904 905 907	EFFECTING A CHANGE IN ISOMERIZATION BY WAVE ENERGY EFFECTING A COLOR CHANGE BY WAVE ENERGY PRODUCTION OF DESIRED COMPOUND BY WAVE ENERGY IN PRESENCE OF A CHEMICALLY DESIGNATED NONREACTANT CHEMICAL TREATING AGENT (EXCLUDING WATER, CHLOROFORM, CARBON TETRACHLORIDE, METHYLENE CHLORIDE OR BENZENE) .Inorganic chemical treating agentMetal treating agentHeavy metal agent .Silicon or boron treating agent
641642643644645647648	plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)Absorbent strip (e.g., cellulose acetate, paper strip, etc.) typeMovable strip .Dielectrophoretic (i.e., uses nonuniform electric field)Isoelectric focusing (i.e., uses pH variation)Isotachophoretic (i.e., displacement electrophoretic) or means to measure ion or particle mobilityParticle bed separator (e.g., inert particles, ion exchange beads, etc.)Bulk separator for solids and liquids (e.g., to dewater solids, clarify water, etc.)With moving or movable electrodeWith moving or movable	900 901 902 903 904 905 907 908	EFFECTING A CHANGE IN ISOMERIZATION BY WAVE ENERGY EFFECTING A COLOR CHANGE BY WAVE ENERGY PRODUCTION OF DESIRED COMPOUND BY WAVE ENERGY IN PRESENCE OF A CHEMICALLY DESIGNATED NONREACTANT CHEMICAL TREATING AGENT (EXCLUDING WATER, CHLOROFORM, CARBON TETRACHLORIDE, METHYLENE CHLORIDE OR BENZENE) .Inorganic chemical treating agentMetal treating agentHeavy metal agent .Silicon or boron treating agent .Phosphorus treating agent
641642643644645647648649	plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)Absorbent strip (e.g., cellulose acetate, paper strip, etc.) typeMovable stripDielectrophoretic (i.e., uses nonuniform electric field)Isoelectric focusing (i.e., uses pH variation)Isotachophoretic (i.e., displacement electrophoretic) or means to measure ion or particle mobilityParticle bed separator (e.g., inert particles, ion exchange beads, etc.)Bulk separator for solids and liquids (e.g., to dewater solids, clarify water, etc.)With moving or movable electrode	900 901 902 903 904 905 907 908 909	EFFECTING A CHANGE IN ISOMERIZATION BY WAVE ENERGY EFFECTING A COLOR CHANGE BY WAVE ENERGY PRODUCTION OF DESIRED COMPOUND BY WAVE ENERGY IN PRESENCE OF A CHEMICALLY DESIGNATED NONREACTANT CHEMICAL TREATING AGENT (EXCLUDING WATER, CHLOROFORM, CARBON TETRACHLORIDE, METHYLENE CHLORIDE OR BENZENE) .Inorganic chemical treating agentMetal treating agentHeavy metal agent .Phosphorus treating agent .Heavy metal treating agent
641642643644645647648649	plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)Absorbent strip (e.g., cellulose acetate, paper strip, etc.) typeMovable strip .Dielectrophoretic (i.e., uses nonuniform electric field)Isoelectric focusing (i.e., uses pH variation)Isotachophoretic (i.e., displacement electrophoretic) or means to measure ion or particle mobilityParticle bed separator (e.g., inert particles, ion exchange beads, etc.)Bulk separator for solids and liquids (e.g., to dewater solids, clarify water, etc.)With moving or movable electrodeWith moving or movable	900 901 902 903 904 905 907 908 909 910	EFFECTING A CHANGE IN ISOMERIZATION BY WAVE ENERGY EFFECTING A COLOR CHANGE BY WAVE ENERGY PRODUCTION OF DESIRED COMPOUND BY WAVE ENERGY IN PRESENCE OF A CHEMICALLY DESIGNATED NONREACTANT CHEMICAL TREATING AGENT (EXCLUDING WATER, CHLOROFORM, CARBON TETRACHLORIDE, METHYLENE CHLORIDE OR BENZENE) .Inorganic chemical treating agentMetal treating agentHeavy metal agent .Phosphorus treating agent .Phosphorus treating agent .Heavy metal treating agent .Sulfur treating agent
641642643644645647648649	plate, fabric, etc.)Cylindrical barrier (e.g., filter, membrane, etc.)Absorbent strip (e.g., cellulose acetate, paper strip, etc.) typeMovable strip .Dielectrophoretic (i.e., uses nonuniform electric field)Isoelectric focusing (i.e., uses pH variation)Isotachophoretic (i.e., displacement electrophoretic) or means to measure ion or particle mobilityParticle bed separator (e.g., inert particles, ion exchange beads, etc.)Bulk separator for solids and liquids (e.g., to dewater solids, clarify water, etc.)With moving or movable electrodeWith moving or movable	900 901 902 903 904 905 907 908 909 910 911	EFFECTING A CHANGE IN ISOMERIZATION BY WAVE ENERGY EFFECTING A COLOR CHANGE BY WAVE ENERGY PRODUCTION OF DESIRED COMPOUND BY WAVE ENERGY IN PRESENCE OF A CHEMICALLY DESIGNATED NONREACTANT CHEMICAL TREATING AGENT (EXCLUDING WATER, CHLOROFORM, CARBON TETRACHLORIDE, METHYLENE CHLORIDE OR BENZENE) .Inorganic chemical treating agentMetal treating agentHeavy metal agentSilicon or boron treating agent .Phosphorus treating agent .Heavy metal treating agent .Sulfur treating agent .Nitrogen treating agent

914 Only carbon, hydrogen or halogen FOR 937 ... Biological, e.g., microbe, atom in treating agent

enzyme, antigen, etc. (204/ 403)

FOREIGN ART COLLECTIONS

FOR 000 CLASS-RELATED FOREIGN DOCUMENTS

Any foreign patents or non-patent literature from subclasses that have been reclassified have been transferred directly to FOR Collections listed below. These Collections contain ONLY foreign patents or non-patent literature. The parenthetical references in the Collection titles refer to the abolished subclasses from which these Collections were derived.

FOR 920 ELECTROLYTIC OBJECT PROTECTION APPARATUS (204/196)

- FOR 921 .Internal battery (204/197)
- FOR 922 ELECTROLYTIC CELLS WITH CURRENT CONTROL MEANS (204/228)
- FOR 923 .With fluid pressure, flow, or level intercontrol (204/229)
- FOR 924 .. Gaseous fluid (204/230)
- FOR 925 .Auxiliary electrode (204/231)
- FOR 926 ELECTROLYTIC FUSED BATH CELLS (204/243 R)
- FOR 927 .Bath current distribution, magnetic field control (204/ 243 M)
- FOR 930 ELECTROLYTIC CELLS WITH FEEDING AND/OR WITHDRAWAL MEANS (204/ 275)
- FOR 931 ELECTROLYTIC ELECTRODE ELEMENTS WITH SUPPORTING MEANS (204/ 286)
- FOR 932 LAMINATED OR COATED ELECTROLYTIC ELECTRODE ELEMENTS (204/290 R)
- FOR 933 .Dielectric film-forming metal base, insoluble conductive coating (204/290 F)
- FOR 934 ELECTROLYTIC ELECTRODE SUPPORTS AND WORK HOLDERS (204/297 R)
- FOR 935 .Workpiece held by magnetism or suction (204/297 M)
- FOR 936 .Workpiece rack (204/297 W)

APPARATUS (204/193)

- .Electrolytic (204/194)
- .. Analysis and testing (204/400)

DIGESTS

DIG 3 AUXILIARY INTERNALLY GENERATED ELECTRICAL ENERGY DIG 4 ELECTROLYSIS CELL COMBINED WITH FUEL CELL DIG 5 MAGNETIC PLUS ELECTROLYTIC DIG 6 UNUSUAL NON-204 USES OF ELECTROLYSIS DIG 7 CURRENT DISTRIBUTION WITHIN THE BATH DIG 8 AC PLUS DC DIG 9 WAVE FORMS DIG 12 ELECTROCHEMICAL MACHINING DIG 13 PURIFICATION AND TREATMENT OF ELECTROPLATING BATHS AND PLATING WASTES